

Refine Search

Search Results -

Terms	Documents
20020028636 or 20040040217 or 5116535.pn. or 5246624.pn. or 6248144.pn. or 6352679.pn. or 5904159.pn.	✓ 7

Database:	<input type="checkbox"/> US Pre-Grant Publication Full-Text Database <input type="checkbox"/> US Patents Full-Text Database <input type="checkbox"/> US OCR Full-Text Database <input type="checkbox"/> EPO Abstracts Database <input type="checkbox"/> JPO Abstracts Database <input type="checkbox"/> Derwent World Patents Index <input type="checkbox"/> IBM Technical Disclosure Bulletins
Search:	<input style="width: 60%; height: 30px;" type="text" value="L4"/> <input type="button" value="Refine Search"/>
	<input type="button" value="Recall Text"/> <input type="button" value="Clear"/> <input type="button" value="Interrupt"/>

Search History

DATE: Monday, October 01, 2007 [Purge Queries](#) [Printable Copy](#) [Create Case](#)

Set	Name	Query	Hit Count	Set result
side by side				
DB=PGPB,USPT; PLUR=YES; OP=ADJ				
L4	20020028636 or 20040040217 or 5116535.pn. or 5246624.pn. or 6248144.pn. or 6352679.pn. or 5904159.pn.		7	L4
L3	(acid or acidic) near4 silica and (polishing or planarizing or planarization or abrasive or cmp or polish).ti. and (basic or alkali) solution		32	L3
DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ				
L2	L1 and (acid or acedic) fumed silica (polishing or planarizing or planarization or abrasive or cmp or polish).ti. and (abrasive or silica or silicon dioxide or silicon oxide or (polishing or planarizing or planarization or cmp) (particle or particulate or grit or grain)) with (volume or vol or "vol." or "vol.%" of "vol%") with (size or diameter) with (nm or nanometer)		1	L2
L1			68	L1

END OF SEARCH HISTORY